

L Number	Hits	Search Text	DB	Time stamp
9	40246	c23c016\$.ipc.	JPO; DERWENT	2002/07/11 11:23
12	675763	h011021\$.ipc.	JPO; DERWENT	2002/07/11 11:23
15	88	(c23c016\$.ipc. h011021\$.ipc.) and (computer same memory same program)	EPO; JPO; DERWENT	2002/07/11 13:21
23	0	(c23c016\$.ipc. h011021\$.ipc.) and (computer same memory same program same gas same purge)	EPO; JPO; DERWENT	2002/07/11 11:29
19	7	(118/\$.ccls. 427/\$.ccls. 438/\$.ccls.) and (computer same memory same program)	EPO; JPO; DERWENT	2002/07/11 13:09
27	9	(c23c016\$.ipc. h011021\$.ipc.) and (computer same memory same program same gas same pressure)	EPO; JPO; DERWENT	2002/07/11 15:52
-	38983	c23c016\$.ipc.	JPO; DERWENT	2002/07/11 14:32
-	660865	h011021\$.ipc.	JPO; DERWENT	2002/07/10 13:49
-	17	118/715.ccls. and (chemisorption "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:38
-	39	118/\$.ccls. and (chemisorption "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:37
-	43	118/\$.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:40
-	330	427/\$.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:52
-	238	438/\$.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:40
-	20	118/715.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition")	USPAT; US-PGPUB	2002/07/09 15:40
-	0	438/\$.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition") and (fluorine "wf6")	USPAT; US-PGPUB	2002/07/09 15:41
-	6	118/\$.ccls. and (chemisorption chemisorb\$3 "ald" "atomic layer deposition") and (fluorine "wf6")	USPAT; US-PGPUB	2002/07/10 13:26
-	25	438/\$.ccls. and (chemisorption chemisorb\$3 "atomic layer deposition") and carrier and (fluorine "wf6")	USPAT; US-PGPUB	2002/07/09 15:54
-	18	427/\$.ccls. and (chemisorption chemisorb\$3 "atomic layer deposition") and carrier and (fluorine "wf6")	USPAT; US-PGPUB	2002/07/09 16:03
-	1	118/\$.ccls. and (chemisorption chemisorb\$3 "atomic layer deposition") and carrier and (fluorine "wf6")	USPAT; US-PGPUB	2002/07/09 16:51
-	0	118/\$.ccls. and (chemisorption chemisorb\$3 "atomic layer deposition" "atomic layer epitaxy") and ("b2h6")	USPAT; US-PGPUB	2002/07/10 13:29
-	10	118/\$.ccls. and (chemisorption chemisorb\$3 "atomic layer deposition" "atomic layer epitaxy") and (diborane boron)	USPAT; US-PGPUB	2002/07/10 16:12
-	40202	c23c016\$.ipc.	JPO; DERWENT	2002/07/11 11:23
-	675062	h011021\$.ipc.	JPO; DERWENT	2002/07/11 11:23
-	9	427/\$.ccls. and ("atomic layer deposition" "atomic layer epitaxy") and (diborane boron "b2h6")	USPAT; US-PGPUB	2002/07/10 13:53
-	32	438/\$.ccls. and ("atomic layer deposition" "atomic layer epitaxy") and (diborane boron "b2h6")	USPAT; US-PGPUB	2002/07/10 13:55
-	4	438/\$.ccls. and ("atomic layer deposition" "atomic layer epitaxy") and (diborane "b2h6")	USPAT; US-PGPUB	2002/07/10 13:56
-	1	(c23c016\$.ipc. h011021\$.ipc.) and ("atomic layer deposition" "atomic layer epitaxy") and (diborane boron "b2h6")	JPO; DERWENT	2002/07/10 13:59
-	34	elers.in.	EPO; JPO; DERWENT	2002/07/10 14:17
-	3	elers.in.	USPAT; US-PGPUB	2002/07/10 14:18
-	66	tungsten same diborane	USPAT; US-PGPUB	2002/07/10 14:26
-	48	tungsten same diborane and (epitaxy deposition)	USPAT; US-PGPUB	2002/07/10 14:41
-	48	((tungsten "wf6") same (diborane "b2h6")) and (epitaxy deposition)	USPAT; US-PGPUB	2002/07/10 14:43

-	8	((tungsten "wf6") same (diborane "b2h6")) and (epitaxy deposition)	EPO; JPO; DERWENT	2002/07/10 14:53
-	12	("4699805" "4957775" "5028565" "5043299" "5250467" "5306666" "5328722" "5342652" "5407698" "5433975" "5769951" "5795824").PN.	USPAT	2002/07/11 15:54
-	2	((("5328722") or ("4957775")).PN.	USPAT;	2002/07/10 15:15
-	0	("atomic layer deposition" "atomic layer epitaxy") and ((computer memory program) with control)	US-PGPUB	2002/07/10 16:22
-	0	("atomic layer deposition" "atomic layer epitaxy") and ((computer memory program) with control)	USPAT;	2002/07/10 16:22
-	260	("atomic layer deposition" "atomic layer epitaxy") and ((computer memory program))	EPO; JPO; DERWENT	2002/07/10 16:23
-	12	("atomic layer deposition" "atomic layer epitaxy") and ((computer memory program))	USPAT;	2002/07/11 11:22
-	1	("5693139").PN.	US-PGPUB	2002/07/11 15:54